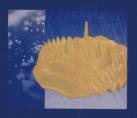
# Physics, Chemistry and Application of Nanostructures

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### Editors

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## AFM INVESTIGATION OF HIGHLY ORDERED NANORELIEF FORMATION BY ANODIC TREATMENT OF ALUMINUM SURFACE

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AFM investigation of aluminum surface after anodic treatment was performed. It was shown that electropolishing in HClO<sub>4</sub> based solutions and long-time anodic oxidation result in formation of highly ordered nanorelief on the aluminum surface. Applications of such treatments in man- and ordereferenties are discussed.

#### 1 Introduction

Porous anodic alumina (PAA) films attract an interest because of possibility of low-cost and short time production of highly ordered manostructures. Possibility of margenic [1], semiconducting [2] and photonic [3] annostructure formation on the basis of PAA was demonstrated hat decade. It is shown that highly ordered PAA films may be formed on pretextured aluminum surface [4]. There are the two commonly used techniques of ordered namorielis formations by electropolishing in perchibirs acid exhanolic solution [5] or by two-step anodization [6]. In this suces, we present APM investigation of the above mentioned processes.

An application of PAA for fabrication of magnetic nanocrystals and carbon nanotubes is demonstrated. A possibility of terabit memory production with PAA templates and nanomasks is analyzed.

#### 2 Sample preparation

Two types of aluminum were used as a substrate for highly ordered nanostructure formation. (1) Al (99,99%) foil is used for electropolishing and two-step anodization experiments; (2) vacuum deposited Al film of  $10\,\mu m$  thickness is used

for the two-step anodization only. Electropolishing was performed in the solution (vol.5)  $\mathrm{HClO}_{c}\mathrm{CH}/\mathrm{HH}/\mathrm{O}$ :  $\mathrm{H-H}/\mathrm{O}$ :  $\mathrm{CH}/\mathrm{HH}/\mathrm{O}$ :  $\mathrm{H-H}/\mathrm{O}$ :

AFM investigation of aluminum surface was performed by scannicng probe microscope "Solver P47H" (NT-MDT Co., Russia) in the non-contact mode.

#### 3 Results and discussion

AFM images of Al surface after electropolishing and anodic oxidation are presented in Fig. 1. The best results of electropolishing is obtained at 60 V etching potential for 30 s. As the result of this process 50 µm of Al was dissolved. The period of the nanopattern was about 80 nm independently on electrolyte concentration. Maximum height of the pattern was 4-6 nm.

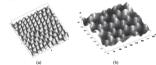


Figure 1. AFM images of Al surface produced by electropolishing (a) and anodic exidation (b) recorded after removal of the exide.

Long-time anodization of Al in the oxalic acid solution produces the nanorelief with 50 nm period and 20 nm height. An acceptable ordering was achieved during 1 h oxidation when 9 um of Al was converted into oxide.

Comparison of the above mentioned techniques shows that long-time oxidation allows to form high contrast nanostructures with the lower Al consumption. Therefore, the second technique is more suitable for the formation of ordered nanostructures not only at a foil surface, but also at evaporated Al films.

Further anodization of the pretreated surfaces showed that the ordering degree is much higher at the long-time anodized surface. By our opinion this results from the large height of a nanorelief.

the large height of a nanorelief.

Additionally, we investigated features of nanoimprinted Al surface anodization.

Nanoimprinting was performed by indentation of surface with the AFM tip.

Pyramidal pits of 20 nm were formed at the surface of annealed Al. This technique allowed us to form an individual carbon nanotube (CNT) in PAA template. CNT deposition was performed by commonly used PECVD process. Also, we formed the arrays of vertically aligned CNT in PAA with cathodically deposited and evaporated metal catalvst.

The ordered PAA back-side and structured Al surface were used to produce strict granter of multi imagenative. We used no An erampolisse critical sea adult-jury effective and the strict granter of th

Thus, the results obtained show the possibility to apply A1 for fabrication of large-area highly-ordered nanostructures.

#### Acknowledgements

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